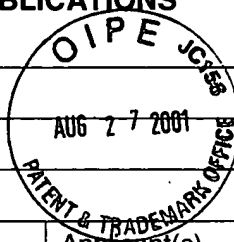


U.S. Department of Commerce, Patent and Trademark Office (PTO Form 1449 modified)		Docket No. <b>APPM/2966</b>	Serial No. <b>09/165,248</b>
<b>SUPPLEMENTAL LIST OF PATENTS AND PUBLICATIONS CITED BY APPLICANT</b>		Applicant <b>S. Rath</b>	Confirmation No.: <b>7619</b>
(Use several sheets if necessary)		Filing Date <b>October 1, 1998</b>	Group <b>2811 2823</b>
Examiner <b>G. Fourson</b>			

**U.S. Patent Documents**

*Examiner Initial		Document Number	Issue Date	Applicant(s) Name	Class	Subclass	Filing Date If Appropriate
G	A1	6,159,871	12-12-2000	Loboda, et al.	438	786	05-29-1998
G	A2	6,147,009	11-14-2000	Grill, et al.	438	780	06-29-1998
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G	A4	5,876,891	03-02-1999	Takimoto, et al.	430	71	05-26-1995
G	A5	5,480,300	01-02-1996	Okoshi, et al.	432	241	05-15-1992
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G	A10	5,103,285	04-07-1992	Furumura et al	357	68	12-19-1988
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	A12						
	A13						

**Foreign Patent Documents**

*Examiner Initial		Document Number	Date	Country	Class	Subclass	Translation	
							YES	NO
	B1							
	B2							
	B3							
	B4							
	B5							

**OTHER ART**

*Examiner Initial		Including Author, Title, Date, Pertinent Pages, Etc.
G	C1	Written Opinion, from PCT/US99/22424, dated April 5, 2001
G	C2	Omar, M.A., "Elementary Solid State Physics: Principles and Applications," Lowell Technological Institute, Addison-Wesley Publishing Company, © 1975, Pages: 124, 125.
	C3	

Examiner <b>Fourson</b>	Date Considered <b>11/18/01</b>
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\*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.